

Resource Summary Report

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Oxford: PlasmaPro 1000 Stratum Plasma Technology

RRID:SCR_020387

Type: Tool

Proper Citation

Oxford: PlasmaPro 1000 Stratum Plasma Technology (RRID:SCR_020387)

Resource Information

URL: <https://plasma.oxinst.com/products/pecvd/plasmapro-1000>

Proper Citation: Oxford: PlasmaPro 1000 Stratum Plasma Technology (RRID:SCR_020387)

Description: Maximised large area etching and deposition production solutions available in load lock or cluster configurations with up to 3 chambers and vacuum load lock as standard with cluster capability options.

Synonyms: Oxford PlasmaPro 1000 Stratum

Resource Type: instrument resource

Keywords: Oxford, Plasma Technology, Instrument, Resource equipment, Equipment, USEdit,

Availability: Commercially available

Resource Name: Oxford: PlasmaPro 1000 Stratum Plasma Technology

Resource ID: SCR_020387

Alternate IDs: Model_Number_Oxford_PlasmaPro_1000

Record Creation Time: 20220129T080350+0000

Record Last Update: 20260815T182636+0000

Ratings and Alerts

No rating or validation information has been found for Oxford: PlasmaPro 1000 Stratum Plasma Technology.

No alerts have been found for Oxford: PlasmaPro 1000 Stratum Plasma Technology.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We have not found any literature mentions for this resource.